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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicants

: Mouli et al.

Serial No.

: 09/648,044

Filed

: August 25, 2000

Title

: METHOD AND DEVICE TO REDUCE GATE-INDUCED DRAIN

LEAKAGE (GIDL) CURRENT IN THIN GATE OXIDE MOSFETs

Docket No.

: MIO 0054 PA

Art Unit

: 2811

Examiner

: O. Nadav

CERTIFICATE OF MAILING

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OFFICIAL DRAFTSPERSON

Assistant Commissioner for Patents Washington, D. C. 20231

Sir or Madam:

TRANSMITTAL OF FORMAL DRAWINGS

Enclosed herewith are formal drawings for the above-identified patent application.

Respectfully submitted,

KILLWORTH, GOTTMAN, HAGAN & SCHAEFF, L.L.P.

Ву

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